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*He/Pr a
Asper
3/9/02*

In re Patent Application of)
Kazuichiroh ITONAGA) Art Unit: 2812
Serial No. 09/966,741) Examiner: Unassigned
Filed: October 1, 2001)
For: SEMICONDUCTOR DEVICE AND)
METHOD FOR MANUFACTURING)
THE SAME)

**PRELIMINARY AMENDMENT AND RESPONSE TO
NOTICE OF INCOMPLETE REPLY(NON-PROVISIONAL)**

Honorable Commissioner of Patents
Washington, D.C. 20231

Sir:

In response to the *Notice of Incomplete Reply* dated January 2, 2002, please amend the above-identified application as follows:

IN THE SPECIFICATION:

Please amend the specification as follows:

Page 17, Paragraph 6, continuing on Page 18

A
FIG. 9A to FIG. 9B are cross-sectional views illustrating some steps in the method of manufacturing a semiconductor device according to the fourth embodiment, from the removal of an unreacted second cobalt film up to the formation of a fourth silicide film.